

Supporting Information

QCM-Based HCl Gas Detection on Dimethylamine-Functionalized Crosslinked Copolymer Films

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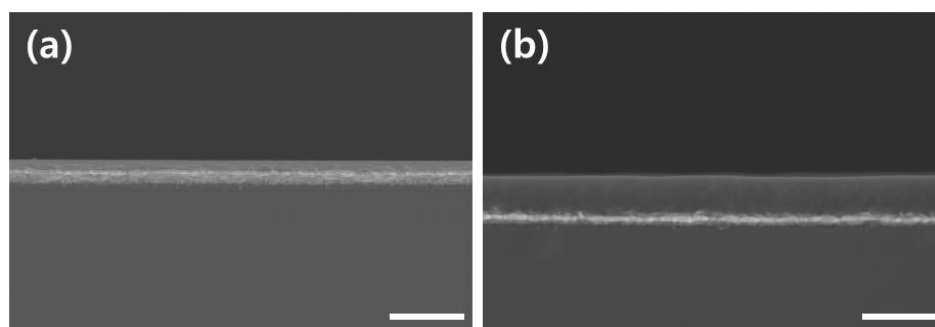


Figure S1. Cross-sectional scanning electron microscopy (SEM) images of poly(DMAEMA-co-EGDMA) films with mass of (a) 1.7 μg and (b) 11.8 μg , respectively. All scale bars are 1 μm .

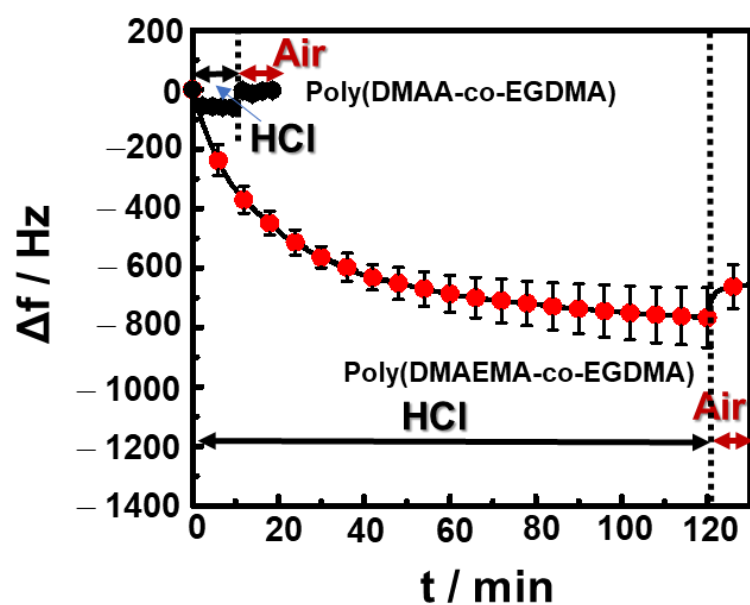


Figure S2. Resonant frequency change (Δf) as a function of time for poly(DMAEMA-co-EGDMA) and poly(DMAA-co-EGDMA) films in 70-ppm HCl and synthetic air flow at 22°C (10% RH). The adsorption-desorption process was performed until the signal stabilized.

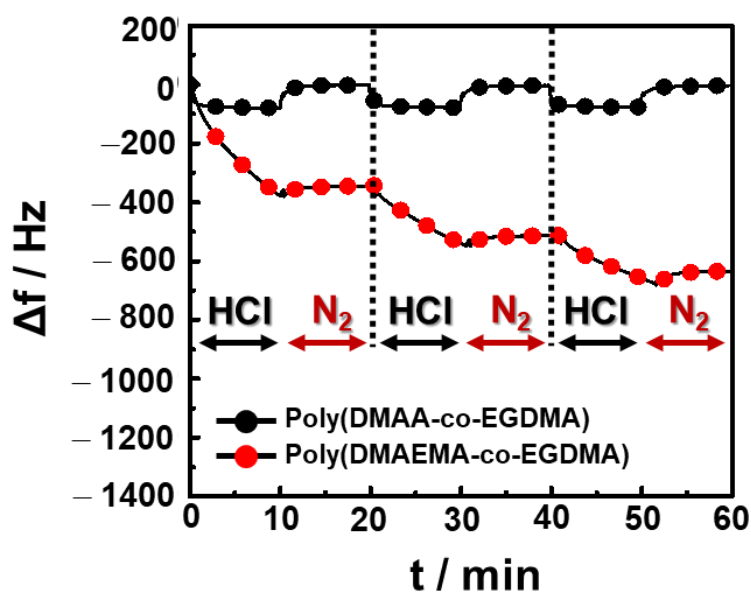


Figure S3. Resonant frequency change (Δf) as a function of time for poly(DMAEMA-co-EGDMA) and poly(DMAA-co-EGDMA) films in 100-ppm HCl and N₂ flow at 22°C (10% RH). Three cycles adsorption-desorption process was performed.

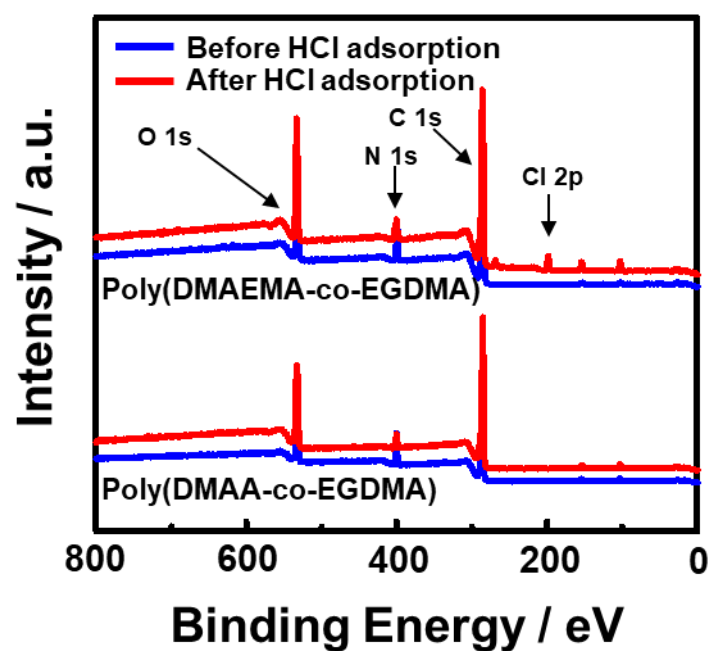


Figure S4. XPS wide scan spectra for poly(DMAEMA-co-EGDMA) and poly(DMAA-co-EGDMA) films before and after HCl adsorption.

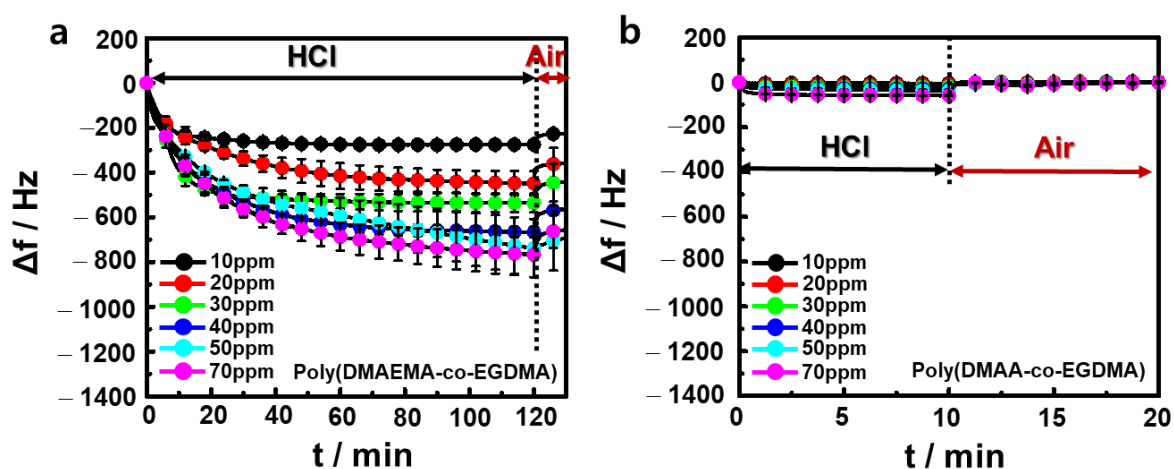


Figure S5. Resonant frequency change (Δf) as a function of time for (a) poly(DMAEMA-co-EGDMA) and (b) poly(DMAA-co-EGDMA) films in HCl gas flow ranging from 10 to 70 ppm at 22 °C and 10% RH during the adsorption process. Synthetic air was used for desorption, and the desorption process was performed until the signal stabilized.

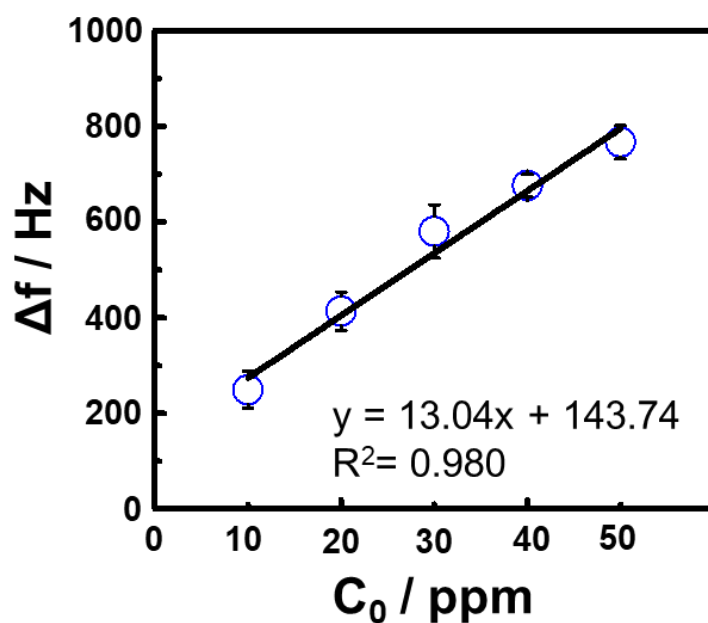


Figure S6. Linear regression curve of poly(DMAEMA-co-EGDMA) for resonant frequency change (Δf) as a function of HCl concentration in HCl ranging from 10 to 50 ppm.

Table S1. Comparison of HCl on various sensor configurations, including the sensitivity and limit of detection in a linear range

Sensor Configuration	Sensitivity	LOD ^a	Reference
PDMAA ^b film	4 Hz/ppm	2.5 ppm	1
PNIPAM ^c nanoparticle	3.8 Hz/ppm	-	2
PNIPAM nanoparticle	3.3 Hz/ppm	-	3
Aminated polystyrene particles	3.88 Hz/ppm	5 ppm	4
Morpholine-functional styrene based copolymer ^d	10 Hz/ppm	-	5
This work	13 Hz/ppm	0.55 ppm	-

^a Limit of detection. ^b Poly(N,N-dimethylacrylamide) ^c Poly(N-isopropylacrylamide) ^d Morpholine-functional styrene-co-chloromethylstyrene copolymer

Table S2. Fitting parameters of the Langmuir and Freundlich models for the adsorption of HCl gas on two crosslinked films.

Samples	Langmuir			Freundlich		
	k_L^a (L/mg)	Q_m^b (mg/g)	R^2	k_F^c (mg/g)(L/mg) ^{1/n}	$1/n^d$	R^2
C3-DMA	17.1	252.4	0.996	521.5	0.52	0.976
C0-DMA	9.6E-4	89627.8	0.890	85.7	1	0.890

^a Langmuir adsorption equilibrium constant. ^b maximum adsorption capacity. ^c Freundlich adsorption equilibrium constant. ^d heterogeneity factor; R^2 correlation coefficient.

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